

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re United States Patent Application of:	) Docket No.: 020732-110.694
Applicant: KORZENSKI, Michael B., et al.	) Examiner: AHMED, Shamim
Application No.: 10/807,858	) Art Unit: 1765
Date Filed: March 24, 2004	) Confirm. No.: 5492
Title: COMPOSITION USEFUL FOR REMOVAL OF BOTTOM ANTI-REFLECTION COATINGS FROM PATTERNEDE ION- IMPLANTED PHOTORESIST WAFERS	) Customer No.:  24239

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**RESPONSE TO THE JANUARY 30, 2007 ADVISORY ACTION; REQUEST FOR A  
ONE-MONTH EXTENSION UNDER 37 CFR §1.136(a); AND REQUEST FOR  
CONTINUED EXAMINATION IN UNITED STATES PATENT APPLICATION NO.  
10/807,858**

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Mail Stop AF  
Commissioner for Patents  
PO Box 1450  
Alexandria, VA 22313-1450

Sir:

This responds to the January 30, 2007 Advisory Action in the above-identified application.

The claims of the application are set out in the following **Section I (The Claims)**.

Remarks addressing the substance of the January 30, 2007 Advisory Action are set out in the **Section II (Remarks)** hereof.